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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/779,842	02/18/2004	Jong Woo Kim	041501-5551-01	9434	
30827	7590 11/09/2005		EXAMINER		
MCKENNA	LONG & ALDRIDGI	DUDEK, J	DUDEK, JAMES A		
1900 K STRE WASHINGTO	ET, NW ON, DC 20006	ART UNIT	PAPER NUMBER		
	,	·	2871		
			DATE MAILED: 11/09/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Appli	cation No.	Applicant(s)				
Office Action Summary		10/77	79,842	KIM ET AL.				
		Exam	iner	Art Unit				
		James	s A. Dudek	2871				
7 Period for F	The MAILING DATE of this commun Reply	ication appears or	the cover sheet v	vith the correspondence add	ress			
THE MA - Extension after SIX - If the per - If NO per - Failure to Any reply	TENED STATUTORY PERIOD F ILING DATE OF THIS COMMUN as of time may be available under the provisions (6) MONTHS from the mailing date of this comr iod for reply specified above is less than thirty (3 iod for reply is specified above, the maximum so reply within the set or extended period for reply received by the Office later than three months atent term adjustment. See 37 CFR 1.704(b).	ICATION. s of 37 CFR 1.136(a). In a nunication. s0) days, a reply within the atutory period will apply a will, by statute, cause the	no event, however, may a e statutory minimum of th and will expire SIX (6) MO e application to become A	reply be timely filed irty (30) days will be considered timely. NTHS from the mailing date of this com BANDONED (35 U.S.C. § 133).	munication.			
Status								
1)⊠ Re	esponsive to communication(s) file	ed on 25 October	2005.					
·		2b)⊠ This action		•				
3)∐ Sii	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
•	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition	of Claims							
4)⊠ CI	aim(s) <u>1-19</u> is/are pending in the	application.						
4a)	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)∐ Cl	aim(s) is/are allowed.							
6)⊠ Cl	aim(s) <u>1-19</u> is/are rejected.							
7)∐ Cl	aim(s) is/are objected to.							
8)∏ CI	aim(s) are subject to restric	ction and/or election	on requirement.					
Application	Papers							
9) <u></u> The	e specification is objected to by th	e Examiner.						
10) <u></u> Th∈	e drawing(s) filed on is/are	: a) ☐ accepted o	or b)□ objected to	by the Examiner.				
Ap	plicant may not request that any obje	ction to the drawing	(s) be held in abeya	nce. See 37 CFR 1.85(a).				
Re	placement drawing sheet(s) including	the correction is re	quired if the drawing	g(s) is objected to. See 37 CFR	t 1.121(d).			
11)∐ Th	e oath or declaration is objected to	by the Examiner	. Note the attache	ed Office Action or form PTC)-152.			
Priority und	ler 35 U.S.C. § 119				•			
a)⊠ <i>i</i>				§ 119(a)-(d) or (f).				
	Certified copies of the priority			Application No.				
2.	Certified copies of the priorityCopies of the certified copies			··· ——	taga			
3.	application from the Internation			Treceived in this National S	lage			
* See	the attached detailed Office action	n for a list of the o	certified copies no	t received.				
					: .			
Attachment(s)		· .						
	References Cited (PTO-892)			Summary (PTO-413)				
· <u> </u>	Draftsperson's Patent Drawing Review (Fon Disclosure Statement(s) (PTO-1449 or			(s)/Mail Date Informal Patent Application (PTO-1	152)			
	o(s)/Mail Date		6) 🔲 Other:		•			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1, 6, 9-11 and 15-19 are rejected under 35 U.S.C. 102(e) as being anticipated by US006888608B2 (608)

Per claim 1, 608 teaches a method of fabricating a liquid crystal display device, comprising: preparing first and second substrates having an active area [display area] and a dummy area [off-display area]; forming at least one first column spacer on the active area on the second substrate [spacers 33 formed in display area]; forming at least one second column spacer in the dummy area on the second substrate [spacers 33 formed in off-display area]; forming a sealant in a periphery of the active area of the second substrate [seal 37, periphery being that area outside and surrounding the display area]; and bonding the first and second substrates to each other [see figure 1].

Per claim 6, 868 teaches the method of claim 1, further comprising forming at least one third column spacer outside the active area of the second substrate [spacer 33 in off-display area]

Per claims 9-10, 868 teaches the method of claim 1, further comprising forming a liquid crystal layer between the first and second substrates [LC 40].

Per claim 11, 868 teaches the method of claim 1, further comprising forming a sliver pattern in a periphery of the active area of the first substrate [the sliver paste, see column 1, lines 55-63].

Per claim 15, 868 teaches the method of claim 1, wherein the first column spacer is formed on the wiring part of the first substrate [see figure 1 and gate 12].

Per claim 16 and 17, 868 teaches the method of claim 1, further comprising: forming a black matrix [36] and a color filter layer [32] on the second substrate; and forming an overcoat layer on the color filter layer [34].

Claim 18 is inherent.

Per claim 19, 608 teaches the step of forming a dummy color filter layer on the periphery of the active area of the second substrate [the spacers 33 are formed from color filters.]

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 2-5, 7-8 and 12-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over 608.

Per claims 2-3, 5 and 8 608 teaches the method of claim 1, but lacks the sealant formed of an organic photo-hardening sealant. However, it was well known to use mixtures of organic photo and thermo hardening seals to ensure a tight seal. Accordingly it would have been obvious to one of ordinary skill at the time of invention to combine the well known photo/thermo seal with 608.

Per claims 4 and 7, 608 teaches the method of claim 1, but lacks the first and second column spacers are about 5 to 30 microns in width. However it was a matter of design when

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choosing the width. If the width is smaller, then the aperture increase and more light will pass. But the space accuracy will decrease. On the other hand, if the width is increased less light will pass, but the space accuracy will increase. It would have been obvious to one of ordinary skill at the time of invention to choose a width between 5 and 30 microns.

Per claim 12, 608 teaches the method of claim 1, but lacks the steps of bonding the first and second substrates to each other includes: loading the second substrate on an upper stage of a bonding machine to face into the first substrate; loading the first substrate on a lower stage of the bonding machine; evacuating a chamber of the bonding machine; aligning the first and second substrates; and attaching the first and second substrates to each other. However, if not explicitly taught each of these method step are well known in the art to ensure proper gap spacing and alignment using an efficient method. Accordingly, it would have been obvious to one of ordinary skill at the time of invention.

Per claim 13, 608 teaches the method of claim 12, but lacks the step of venting the chamber to an atmospheric pressure to press the attached substrates by difference between an inner pressure of the bonded substrates and the atmospheric pressure and applying a UV-ray to the attached substrates to harden the sealant. However is was also well known to create a vacuum of at least one atmosphere to apply pressure on the substrates and use UV light to harden the seal to ensure the liquid crystal is seal properly. It would have been obvious to one of ordinary skill at the time of invention.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to James A. Dudek whose telephone number is 571-272-2290. The examiner can normally be reached on 9:00-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert H. Kim can be reached on 571-272-2293. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217/9197 (toll-free).

Jantes A. Dudek
Primary Examiner
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